



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

April 8, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG790612343

Report verification at [igi.org](#)

PROPORTIONS

Medium To Slightly Thick (Faceted)

15%

45%

59%

64.5%

Pointed

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used

LABORATORY GROWN DIAMOND REPORT

April 8, 2026

IGI Report Number

Description

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

LG790612343

LABORATORY GROWN DIAMOND

MARQUISE BRILLIANT

11.53 X 5.89 X 3.80 MM

1.48 CARAT

E

VVS 2

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

Medium To Slightly Thick (Faceted)

15%

45%

59%

64.5%

Pointed

IGI

April 8, 2026

IGI Report No LG790612343

MARQUISE BRILLIANT

11.53 X 5.89 X 3.80 MM

1.48 CARAT

E

VVS 2

64.5%

59%

Medium to Slightly Thick (Faceted)

Pointed

EXCELLENT

EXCELLENT

NONE

IGI LG790612343

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

© IGI 2020, International Gemological Institute

FD - 10 20

THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES.